

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Patent No. .... 6878507 B2  
Patent Issue Date ..... April 12, 2005  
Application Serial No. .... 09885393  
Filing Date ..... June 19, 2001  
Assignee ..... Micron Technology, Inc.  
Inventorship ..... Richard Holscher et al.  
Attorney's Docket No. .... MI22-1694  
Title: ..... Semiconductor Processing Methods

**REQUEST FOR CERTIFICATE OF CORRECTION OF PATENT**  
**FOR PTO MISTAKE (37 C.F.R. 1.322(a))**

To: Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

ATTN: Decision and Certificate of Correction  
Branch of the Patent Issue Division

From: Robert C. Hyta (Tel. 509-624-4276; Fax 509-838-3424)  
Wells St. John P.S.  
601 W. First Avenue, Suite 1300  
Spokane, WA 99201-3828

Sir/Madam:

It is hereby requested that a Certificate of Correction be issued with respect to US 6878507 B2, granted April 12, 2005, in accordance with the Certificate of Correction form attached hereto.

The errors listed on the Certificate of Correction form were apparently incurred through the fault of the PTO as will be disclosed by the records of files in the Office. A copy of the initialed Form-1449 considered by the Examiner showing the references listed on the attached Form PTO-1050 is attached. This document was downloaded from the application file in PAIR.

Since this Certificate of Correction is being requested due to PTO errors, it is believed that no fee is due. However, in the event that a fee is required for issuance of this Certificate of Correction, please charge the fee specified under 37 C.F.R. § 1.20(a) to Deposit Account No. 23-0925. Please credit Deposit Account No. 23-0925 with any overpayment of the above fee.

Respectfully submitted,

Dated: 6/13/08

By:   
Robert C. Hyta  
Reg. No. 46,791

UNITED STATES PATENT AND TRADEMARK OFFICE  
CERTIFICATE OF CORRECTION

Page 1 of 1

PATENT NO. : 6878507B2

APPLICATION NO.: 09885393

DATED : April 12, 2005

INVENTOR(S) : Holscher, Richard D.; Yin, Zhiping;  
Glass, Thomas R.

It is certified that errors appears in the above-identified patent and that  
said Letters Patent is hereby corrected as shown below:

Pg. 3, col. 2, - Other Publications

Insert --Abstract: Loboda, M. et al., "Using Trimethylsilane to Improve  
Safety, Throughput and Versatility in PECVD Processes", Electrochemical  
Society Mtg., #358, Montreal, Quebec, Vol. MA 97-1, 1997, pg. 454--

Pg. 3, col. 2, - Other Publications

Insert --Julius Grant, "Hack's Chemical Dictionary", McGraw-Hill Book  
Co., 1969, Fourth Ed., pg. 27--

**Mailing Address of Sender:**

Robert C. Hyta  
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Form PTO-1449

U.S. DEPARTMENT OF COMMERCE  
PATENT AND TRADEMARK OFFICEATTY. DOCKET NO.  
MI22-1504SERIAL NO.  
09/641,826LIST OF ARTS CITED BY APPLICANT  
(Use several sheets if necessary)APPLICANT  
Weimla Li et al.FILING DATE  
RCE Filed HerewithGROUP  
1755

## U.S. PATENT DOCUMENTS

*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
AA		App. 09/146,842 (as filed and amended)		Yin et al.			9/98
AB		App. 09/146,843 (as filed and amended)		Li et al.			9/98
AC		App. 09/030,618 (as filed and amended)		Hausler et al.			2/98
AD		App. 09/234,233 (as filed and amended)		Li et al.			1/99
AE							
AF							
AG							
AH							
AI							
AJ							

## FOREIGN PATENT DOCUMENTS

		Document Number	Date	Country	Class	Subclass	Translation	
							Yes	No
AK								
AL								
AM								
AN								
AO								

## OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, Etc.)

VM	AP		ABSTRACT: Loboda, M. et al., "Using Trimethylsilane to Improve Safety, Throughput and Versatility in PECVD Processes", Electrochemical Society Meeting Abstract No. 358, 191 <sup>st</sup> Meeting, Montreal, Quebec, Vol. MA 97-1, 1997, page 454.
VM	AQ		Julius Grant, "Hack's Chemical Dictionary", McGraw-Hill Book Company 1969, Fourth Edition, page 27.
	AR		

EXAMINER	K. Dreda	DATE CONSIDERED	8-8-02
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\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.